

U.S. PRO
66-996676
11/30/6

Class	ISSUE C
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STATE OF NEW YORK

U.S. **UTILITY** Patent Application

O.I.P.E. SCANNED <u>LM3</u> Q.A. <u>VRE</u>	PATENT DATE
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APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/996676	F	430		1752	

APPLICANTS

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Positive-working photoresist composition:

TITLE

PTO-2040
12/89

ISSUING CLASSIFICATION									
ORIGINAL			CROSS REFERENCE(S)						
CLASS		SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)					
430			430	905	914				
INTERNATIONAL CLASSIFICATION									
6	03	F	1 / 004						

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	Sheets Drwg. _____	Figs. Drwg. _____	Print Fig. _____	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed. <input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ 	_____ (Assistant Examiner) (Date)			NOTICE OF ALLOWANCE MAILED	
	_____ <i>Rosemary Ashton</i> 3/18/03 (Primary Examiner) (Date)			ISSUE FEE	
				Amount Due	Date Paid
_____ The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) (Date)			ISSUE BATCH NUMBER	

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